SULFIDATION PROCESSING AND Cr ADDITION TO IMPROVE OXIDATION RESISTANCE OF Ti-AI INTERMETALLIC COMPOUNDS AT ELEVATED TEMPERATURES

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Abstract

A novel process is proposed to improve oxidation resistance of Ti-Al intermetallic compounds at elevated temperatures by both Cr addition and pre-sulfidation, where TiAl alloys with/or without Cr addition were sulfidized at 1173K for 86.4ks at a 1.3 Pa sulfur partial pressure in a H₂-H₂S gas mixture. The pre-sulfidation treatment formed a thin Cr-Al alloy layer as well as 7 10 micrometer TiAl₃ and TiAl2 layer, due to selective sulfidation of Ti. Oxidation resistance of the pre-sulfidation processed TiAl 4Cr alloy was examined under isothermal and heat cycle conditions between room temperature and 1173K in air. Changes in TiAl₃ into TiAl₂ and then TiAl phases as well as their effect on oxidation behavior were investigated and compared with the oxidation behavior of the TiAl-4Cr alloy as well as TiAl and pre-sulfidation processed TiAl alloys. After oxidation for up to 2.7Ms a protective Al₂O₃ scale was formed, and the pre-formed TiAl₃ changed into TiAl₂ and the Al₂Cr phase changed into a CrAlTi phase between the Al₂O₃ scale and TiAl₂ layer. The pre-sulfidation processed TiAl-4Cr alloy had very good oxidation resistance for longer times, up to 2.7 Ms, in contrast to those observed for the pre-sulfidation processed TiAl alloy where localized oxidation occurred after 810ks and both the TiAl and TiAl-4Cr alloys themselves corroded rapidly from the initial stage of oxidation